

| | Type | Hits | Search Text |
|----|------|--------|--|
| 1 | BRS | 10185 | (hous\$5 capsul\$6 encapsul\$5) same (fiber\$1 fibre\$1 waveguide\$1 wave near1 guid\$3) same coupl\$4 |
| 2 | BRS | 391 | (sleev\$3 ferrul\$4) same (fiber\$1 fibre\$1 waveguide\$1 wave near1 guid\$3) same align\$5 same detect\$6 |
| 3 | BRS | 173292 | (backreflect\$5 back near4 reflect\$4) (reflect\$5 near9 (nois\$4 slop\$2 angl\$3)) |
| 4 | BRS | 861 | (sleev\$3 ferrul\$4 connector\$2) same (fiber\$1 fibre\$1 waveguide\$1 wave near1 guid\$3) same align\$5 same mold\$4 |
| 5 | BRS | 3 | S1 and S2 and S4 and S5 |
| 6 | BRS | 9 | S3 and S4 |
| 7 | BRS | 1481 | (sleev\$3 ferrul\$4 connect\$2) same (fiber\$1 fibre\$1 waveguide\$1 wave near1 guid\$3) same align\$5 same detect\$6 |
| 8 | BRS | 6247 | (sleev\$3 ferrul\$4) same (fiber\$1 fibre\$1 waveguide\$1 wave near1 guid\$3) same align\$5 |
| 9 | BRS | 65 | S1 and S8 and S9 and S4 |
| 10 | BRS | 38 | S10 and (sleev\$3 ferrul\$4 connect\$2) same (fibers fibres waveguides) same align\$5 |
| 11 | BRS | 38 | S10 and (sleev\$3 ferrul\$4 connect\$2) same (fibers fibres waveguides (fiber\$1 near2 bundl\$2)) same align\$5 |
| 12 | BRS | 71147 | (hous\$5 capsul\$6 encapsul\$5) same (fiber\$1 fibre\$1 waveguide\$1 wave near1 guid\$3) |
| 13 | BRS | 181011 | (backreflect\$5 back near4 reflect\$4) (reflect\$5 near12 (nois\$4 slop\$2 angl\$3)) |
| 14 | BRS | 51526 | align\$5 same mold\$4 |
| 15 | BRS | 7 | S2 and S13 and S14 and S15 |

| | DBs | Time Stamp |
|----|---------------------------------------|------------------|
| 1 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:23 |
| 2 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:27 |
| 3 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:24 |
| 4 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:58 |
| 5 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:26 |
| 6 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 13:24 |
| 7 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 13:34 |
| 8 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 13:32 |
| 9 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 13:33 |
| 10 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 13:45 |
| 11 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 13:48 |
| 12 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:23 |
| 13 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:31 |
| 14 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:25 |
| 15 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:31 |

| | Type | Hits | Search Text |
|----|------|--------|---|
| 16 | BRS | 251833 | (backreflect\$5 back near4 reflect\$4) (reflect\$5 same (nois\$4 slop\$2 angl\$3)) |
| 17 | BRS | 0 | S18 not S17 |
| 18 | BRS | 3 | S18 not S16 |
| 19 | BRS | 19 | (sleev\$3 ferrul\$4 connector\$2) near7 slope same (reflect\$5 nois\$3) |
| 20 | BRS | 0 | S2 and S13 and S19 and S15 |
| 21 | BRS | 0 | S2 and S13 and S19 and S21 |
| 22 | BRS | 0 | S2 and S13 and S21 and S15 |
| 23 | BRS | 1 | S2 and S13 and S21 |
| 24 | BRS | 33559 | (sleev\$3 ferrul\$4 connector\$2) near7 (angl\$2 slope) |
| 25 | BRS | 31 | (sleev\$3 ferrul\$4 connector\$2) same (fiber\$1 fibre\$1 waveguide\$1 wave near1 guid\$3) same align\$5 same detect\$6 same mold\$4 |
| 26 | BRS | 2 | "6641310".pn. |
| 27 | BRS | 4 | ("6641310" "5917976").pn. |
| 28 | BRS | 4 | ("6641310" "5917976").pn. |
| 29 | BRS | 2 | ("6641310" "5917976").pn. |
| 30 | BRS | 1173 | (sleev\$3 ferrul\$4 coupler connector) near5 (slope) |
| 31 | BRS | 11 | S5 and S31 |
| 32 | BRS | 146 | (sleev\$3 ferrul\$4 coupler connector) near4 end\$1 near4 (angle\$1 slope\$1) same reflect\$5 |
| 33 | BRS | 49 | (S1 S2 S5) and S33 |
| 34 | BRS | 3 | S1 and (S2 S5) and S33 |
| 35 | BRS | 10 | S2 and S13 and S17 and S15 |

| | DBs | Time Stamp |
|----|---------------------------------------|-------------------|
| 16 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:31 |
| 17 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:32 |
| 18 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:32 |
| 19 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:37 |
| 20 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:34 |
| 21 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:34 |
| 22 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:36 |
| 23 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:36 |
| 24 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:56 |
| 25 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:46 |
| 26 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:46 |
| 27 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:47 |
| 28 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:47 |
| 29 | US-PGPUB; USPAT | 2005/03/17 14:49 |
| 30 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 15:10 |
| 31 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 14:58 |
| 32 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 15:11 |
| 33 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 15:40 |
| 34 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 15:40 |
| 35 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 15:44 |

| | Type | Hits | Search Text |
|----|------|------|--|
| 36 | BRS | 27 | ("20030063832" "6782146" "5857050" "20050013551" "6017154" "6425696" "6641310" "20050013551" "5857050" "20020025125" "20040028349" "5857050" "5631991" "4215937" "20040028349" "20030021537" "20020106149" "6603906" "5631991" "4215937" "20040028349" "20030021537" "20020106149" "6603906" "5631991" "4215937") .pn. |
| 37 | BRS | 14 | ("20030063832" "6782146" "5857050" "20050013551" "6017154" "6425696" "6641310" "20050013551" "5857050" "20020025125" "20040028349" "5857050" "5631991" "4215937" "20040028349" "20030021537" "20020106149" "6603906" "5631991" "4215937" "20040028349" "20030021537" "20020106149" "6603906" "5631991" "4215937") .pn. |
| 38 | BRS | 1 | 10/663665 |
| 39 | BRS | 1 | S38 and (connect\$5 same align\$5) |

| | DBs | Time Stamp |
|----|---------------------------------------|------------------|
| 36 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/17 15:48 |
| 37 | US-PGPUB; USPAT | 2005/03/18 11:15 |
| 38 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/18 11:50 |
| 39 | US-PGPUB; USPAT; EPO; JPO; DERWENT | 2005/03/18 11:51 |

Day : Friday
Date: 3/18/2005

Time: 15:54:44


PALMINTRANET

Inventor Name Search Result

Your Search was:

Last Name = WU

First Name = SHYE-LIN

| Application# | Patent# | Status | Date Filed | Title | Inventor Name |
|-----------------|----------------|--------|------------|---|---------------|
| <u>07939244</u> | <u>5347161</u> | 150 | 09/02/1992 | STACKED-LAYER STRUCTURE POLYSILICON EMITTER CONTACTED P-N JUNCTION DIODE | WU, SHYE-LIN |
| <u>07987905</u> | Not Issued | 161 | 12/04/1992 | STACKED-LAYER STRUCTURE POLYSILICON EMITTER CONTACTED P-N JUNCTION DIODE | WU, SHYE-LIN |
| <u>08096505</u> | <u>5429966</u> | 150 | 07/22/1993 | METHOD OF FABRICATING A TEXTURED TUNNEL OXIDE FOR EEPROM APPLICATIONS | WU, SHYE-LIN |
| <u>08150385</u> | Not Issued | 161 | 11/09/1993 | MOS TRANSISTOR WITH STACKED-SILICON LAYERS OF GATE STRUCTURE | WU, SHYE-LIN |
| <u>08213855</u> | Not Issued | 161 | 03/16/1994 | TUNNEL OXYNITRIDE STRUCTURE AND METHOD FOR FABRICATING THE SAME | WU, SHYE-LIN |
| <u>08297121</u> | Not Issued | 161 | 08/29/1994 | TUNNEL OXYNITRIDE STRUCTURE AND METHOD FOR FABRICATING THE SAME | WU, SHYE-LIN |
| <u>08585033</u> | <u>5650351</u> | 150 | 01/11/1996 | METHOD TO FORM A CAPACITOR HAVING MULTIPLE PILLARS FOR ADVANCED DRAMS | WU, SHYE-LIN |
| <u>08623678</u> | <u>5656536</u> | 150 | 03/29/1996 | METHOD OF MANUFACTURING A CROWN SHAPED CAPACITOR WITH HORIZONTAL FINES FOR HIGH DENSITY DRAMS | WU, SHYE-LIN |
| <u>08624946</u> | <u>5585295</u> | 150 | 03/29/1996 | METHOD FOR FORMING INVERSE-T GATE LIGHTLY- DOPED DRAIN (ITLDD) DEVICE | WU, SHYE-LIN |
| | | | | | |

| | | | | | |
|-----------------|----------------|-----|------------|--|--------------|
| <u>08624953</u> | Not Issued | 161 | 03/29/1996 | CROWN SHAPED CAPACITOR WITH HORIZONTAL FINS FOR HIGH DENSITY DRAMS | WU, SHYE-LIN |
| <u>08626164</u> | <u>5658822</u> | 150 | 03/29/1996 | LOCOS METHOD WITH DOUBLE POLYSILICON/SILICON NITRIDE SPACER | WU, SHYE-LIN |
| <u>08644807</u> | Not Issued | 161 | 05/10/1996 | METHOD FOR FORMING A SHALLOW JUNCTION | WU, SHYE-LIN |
| <u>08658861</u> | Not Issued | 161 | 05/31/1996 | METHOD FOR FORMING POLYCID GATE | WU, SHYE-LIN |
| <u>08685306</u> | <u>5837585</u> | 150 | 07/23/1996 | METHOD OF FABRICATING FLASH MEMORY CELL | WU, SHYE-LIN |
| <u>08708236</u> | <u>5933742</u> | 150 | 09/06/1996 | MULTI-CROWN CAPACITOR FOR HIGH DENSITY DRAMS | WU, SHYE-LIN |
| <u>08709161</u> | Not Issued | 161 | 09/06/1996 | PROCESS FOR FORMING SELF- ALIGNED TWIN-TUB WITH SMOOTH SURFACE TOPOGRAPHY | WU, SHYE-LIN |
| <u>08709169</u> | <u>5747377</u> | 150 | 09/06/1996 | PROCESS FOR FORMING SHALLOW TRENCH ISOLATION | WU, SHYE-LIN |
| <u>08746856</u> | Not Issued | 161 | 11/18/1996 | STRUCTURE OF POROUS-SI CAPACITORS FOR HIGH DENSITY DRAMS CELL | WU, SHYE-LIN |
| <u>08746857</u> | <u>5723373</u> | 150 | 11/18/1996 | METHOD OF MAKING POROUS- SI CAPACITORS FOR HIGH DENSITY DRAMS CELL | WU, SHYE-LIN |
| <u>08746858</u> | <u>5814549</u> | 150 | 11/18/1996 | METHOD OF MAKING POROUS- SI CAPACITOR DRAM CELL | WU, SHYE-LIN |
| <u>08757102</u> | <u>5721168</u> | 150 | 12/02/1996 | METHOD FOR FORMING A RING-SHAPE CAPACITOR | WU, SHYE-LIN |
| <u>08759615</u> | <u>5759893</u> | 150 | 12/05/1996 | METHOD OF FABRICATING A RUGGED-CROWN SHAPED CAPACITOR | WU, SHYE-LIN |
| <u>08763282</u> | <u>5679601</u> | 150 | 12/10/1996 | LOCOS METHOD USING ENCAPSULATING POLYSILICON/SILICON NITRIDE SPACER | WU, SHYE-LIN |
| <u>08783754</u> | <u>5670397</u> | 150 | 01/16/1997 | DUAL POLY-GATE DEEP SUBMICRON CMOS WITH BURIED CONTACT TECHNOLOGY | WU, SHYE-LIN |
| <u>08825720</u> | <u>5854101</u> | 150 | 04/04/1997 | LOW MASK COUNT CMOS PROCESS WITH INVERSE-T | WU, SHYE-LIN |

| | | | | | |
|-----------------|----------------|-----|------------|---|--------------|
| | | | | GATE LDD STRUCTURE | |
| <u>08859753</u> | <u>5736446</u> | 150 | 05/21/1997 | METHOD OF FABRICATING A MOS DEVICE HAVING A GATE-SIDE AIR-GAP STRUCTURE | WU, SHYE-LIN |
| <u>08859754</u> | <u>5773348</u> | 150 | 05/21/1997 | METHOD OF FABRICATING A SHORT-CHANNEL MOS DEVICE | WU, SHYE-LIN |
| <u>08877127</u> | Not Issued | 161 | 06/17/1997 | METHOD FOR FORMING NESTED CAPACITOR AND DEVICE FORMED THEREBY | WU, SHYE-LIN |
| <u>08881753</u> | <u>5849617</u> | 150 | 06/24/1997 | METHOD FOR FABRICATING A NESTED CAPACITOR | WU, SHYE-LIN |
| <u>08881774</u> | <u>5750431</u> | 150 | 06/24/1997 | METHOD FOR FABRICATING A STACKED CAPACITOR | WU, SHYE-LIN |
| <u>08881776</u> | <u>5756388</u> | 150 | 06/24/1997 | METHOD FOR FABRICATING A RAKE-SHAPED CAPACITOR | WU, SHYE-LIN |
| <u>08906552</u> | <u>5937281</u> | 150 | 08/05/1997 | METHOD TO FORM METAL-TO-METAL ANTIFUSE FOR FIELD PROGRAMMABLE GATE ARRAY APPLICATIONS USING LIQUID PHASE DEPOSITION (LPD) | WU, SHYE-LIN |
| <u>08935544</u> | <u>6033956</u> | 150 | 09/23/1997 | METHOD TO FORM CONTACTLESS ARRAY FOR HIGH DENSITY NONVOLATILE MEMORIES | WU, SHYE-LIN |
| <u>08953609</u> | <u>5915182</u> | 150 | 10/17/1997 | MOSFET WITH SELF-ALIGNED SILICIDATION AND GATE-SIDE AIR-GAP STRUCTURE | WU, SHYE-LIN |
| <u>08954412</u> | <u>5930622</u> | 150 | 10/20/1997 | METHOD FOR FORMING A DRAM CELL WITH A DOUBLE-CROWN SHAPED CAPACITOR | WU, SHYE-LIN |
| <u>08954413</u> | <u>5866455</u> | 150 | 10/20/1997 | METHOD FOR FORMING A DRAM CELL WITH A MULTIPLE PILLAR-SHAPED CAPACITOR | WU, SHYE-LIN |
| <u>08954416</u> | <u>5834353</u> | 150 | 10/20/1997 | METHOD OF MAKING DEEP SUB-MICRON METER MOSFET WITH A HIGH PERMITIVITY GATE DIELECTRIC | WU, SHYE-LIN |
| <u>08954448</u> | Not Issued | 161 | 10/20/1997 | METHOD FOR FORMING A RUGGED STACKED TRENCH (RST) CAPACITOR OF A DRAM CELL | WU, SHYE-LIN |
| <u>08958536</u> | <u>6027981</u> | 150 | 10/27/1997 | METHOD FOR FORMING A | WU, SHYE-LIN |

| | | | | | |
|-----------------|----------------|-----|------------|---|--------------|
| | | | | DRAM CELL WITH A FORK-SHAPED CAPACITOR | |
| <u>08960870</u> | <u>6011286</u> | 150 | 10/31/1997 | DOUBLE STAIR-LIKE CAPACITOR STRUCTURE FOR A DRAM CELL | WU, SHYE-LIN |
| <u>08962003</u> | <u>6020609</u> | 150 | 10/31/1997 | DRAM CELL WITH A RUGGED STACKED TRENCH (RST) CAPACITOR | WU, SHYE-LIN |
| <u>08962623</u> | <u>5766995</u> | 150 | 11/03/1997 | METHOD FOR FORMING A DRAM CELL WITH A RAGGED POLYSILICON CROWN-SHAPED CAPACITOR | WU, SHYE-LIN |
| <u>08962625</u> | <u>5807777</u> | 150 | 11/03/1997 | METHOD OF MAKING A DOUBLE STAIR-LIKE CAPACITOR FOR A HIGH DENSITY DRAM CELL | WU, SHYE-LIN |
| <u>08984871</u> | <u>6180988</u> | 150 | 12/04/1997 | SELF-ALIGNED SILICIDED MOSFETS WITH A GRADED S/D JUNCTION AND GATE-SIDE AIR-GAP STRUCTURE | WU, SHYE-LIN |
| <u>08990117</u> | <u>5913118</u> | 150 | 12/12/1997 | METHOD OF MANUFACTURING TRENCH DRAM CELLS WITH SELF-ALIGNED FIELD PLATE | WU, SHYE-LIN |
| <u>08990167</u> | <u>6100127</u> | 150 | 12/12/1997 | SELF-ALIGNED SILICIDED MOS TRANSISTOR WITH A LIGHTLY DOPED DRAIN BALLAST RESISTOR FOR ESD PROTECTION | WU, SHYE-LIN |
| <u>08994053</u> | <u>5856226</u> | 150 | 12/19/1997 | METHOD OF MAKING ULTRA-SHORT CHANNEL MOSFET WITH SELF-ALIGNED SILICIDED CONTACT AND EXTENDED S/D JUNCTION | WU, SHYE-LIN |
| <u>08994178</u> | <u>6087234</u> | 150 | 12/19/1997 | METHOD OF FORMING A SELF-ALIGNED SILICIDE MOSFET WITH AN EXTENDED ULTRA-SHALLOW S/D JUNCTION | WU, SHYE-LIN |
| <u>08995569</u> | <u>5966612</u> | 150 | 12/22/1997 | METHOD OF MAKING A MULTIPLE MUSHROOM SHAPE CAPACITOR FOR HIGH DENSITY DRAMS | WU, SHYE-LIN |
| <u>08996694</u> | <u>6022769</u> | 150 | 12/23/1997 | METHOD OF MAKING SELF-ALIGNED SILICIDED MOS TRANSISTOR WITH ESD PROTECTION IMPROVEMENT | WU, SHYE-LIN |

Search and Display More Records.

| | Last Name | First Name | |
|---------------------------------|---------------------------------|---------------------------------------|---------------------------------------|
| Search Another: Inventor | <input type="text" value="WU"/> | <input type="text" value="SHYE-LIN"/> | <input type="button" value="Search"/> |

To go back use Back button on your browser toolbar.

Back to [PALM](#) | [ASSIGNMENT](#) | [OASIS](#) | [Home page](#)